PATENT Customer No. 22,852 Attorney Docket No. 04329,2543-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Divisional Application of Serial No. 09/812,688, filed March 21, 2001, of:)
Masamitsu ITOH et al.) Group Art Unit: To be Assigned
Application No.: To be Assigned) Examiner: To be Assigned)
Filed: Herewith)
For: PATTERN FORMATION MATERIAL, PATTERN FORMATION METHOD, AND EXPOSURE MASK FABRICATION METHOD	,

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. § 1.97(b)

Pursuant to 37 C.F.R. §§ 1.56 and 1.97(b), Applicants bring to the attention of the Examiner the documents listed on the attached PTO 1449. This Information Disclosure Statement is being filed together with the above-referenced divisional application.

Copies of the listed documents were previously submitted in a prior application, Application No. 09/812,688, filing date March 21, 2001, upon which Applicants rely for the benefits provided in 35 U.S.C. § 120. Applicants respectfully request that the Examiner consider the listed documents and indicate that they were considered by making appropriate notations on the attached form.

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The following is a concise statement of relevance of the non-English language documents:

- 1. Japanese Patent Application No. 8-262721
- 2. Japanese Patent Application No. 9-6002
- 3. Japanese Patent Application No. 9-6003
- 4. Japanese Patent Application No. 9-22117
- 5. Japanese Patent Application No. 9-127698
- 6. Japanese Patent Application No. 10-10738
- 7. Japanese Patent Application No. 9-219355

Japanese Patent Application numbers 1-7 disclose resist materials for optical lithography. In addition, Japanese Patent Application Nos. 9-6002 and 8-262721 were cited by the Examiner as an Office Action dated August 14, 2003.

8. <u>Japanese Patent Application NO. 11-271965</u> disclosed a resist process for electron beam lithography. In addition, Japanese Patent Application No. 11-271965 and a partial machine translation thereof were cited by the Examiner in an Office Action dated August 14, 2002.

In lieu of a statement of relevance or translation of the non-English documents, an English language version of a search report from the Patent Office in a corresponding application citing these documents and setting forth the relevance thereof is enclosed.

In lieu of a statement of relevance or translation of the non-English documents

Japanese Patent Application Nos. 11-231542, 11-218925, and 11-282166, an English

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language version of a search report from the Korean Patent Office in a corresponding application citing these documents and setting forth the relevance thereof is enclosed.

In addition, in lieu of a statement of relevance or translation of the non-English documents Japanese Patent Application Nos. 2000-66405, 9-179301, and 11-15163, an English language version of a search report from the Japanese Patent Office in a corresponding application citing these documents and setting forth the relevance thereof is enclosed.

This submission does not represent that a search has been made or that no better art exists and does not constitute an admission that each or all of the listed documents are material or constitute "prior art." If the Examiner applies any of the documents as prior art against any claim in the application and applicants determine that the cited documents do not constitute "prior art" under United States law, applicants reserve the right to present to the office the relevant facts and law regarding the appropriate status of such documents.

Applicants further reserve the right to take appropriate action to establish the patentability of the disclosed invention over the listed documents, should one or more of the documents be applied against the claims of the present application.

If there is any fee due in connection with the filing of this Statement, please charge the fee to our Deposit Account No. 06-0916.

FINNEGAN HENDERSON FARABOW GARRETT & DUNNER LLL

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW, GARRETT & DUNNER, L.L.P. Richard V. Burgujian
Reg. No. 31,744

Dated: September 22, 2003

FINNEGAN HENDERSON FARABOW GARRETT & DUNNERLLP

INFORMATION DISCLOSURE CITATION

Atty. Docket No.	4329.2543-01	Appln. No.	n/a
Applicant	Masamitsu ITOH et al.		
Filing Date	September 22, 2003	Group:	n/a

U.S. PATENT DOCUMENTS						
Examiner Initial*	Document Number	Issue Date	Name	Class	Sub Class	Filing Date If Appropriate
	5,962,180	10/5/99	Iwanaga et al.			
	5,985,524	11-1999	Allen et al.			<u></u>
	6,380,317	04-2002	Malik et al.			
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FOREIGN PATENT DOCUMENTS					
Document Number	Publication Date	Country	Class	Sub Class	Translation Yes or No
WO 99/27418	6/3/99	PCT			
8-262721	10/11/96	Japan			No
9-6002	1/10/97	Japan			No
9-6003	1/10/97	Japan			No
9-22117	1/21/97	Japan			No
9-127698	5/16/97	Japan			No
10-10738	1/16/98	Japan			No
9-219355	8/19/97	Japan			No
11-271965	10/8/99	Japan			No
11-231542	08/1999	Japan			No
11-218925	08/1999	Japan			No
11-282166	10/1999	Japan			No
2000-66405	03/03/2000	Japan			No
9-179301	07/11/1997	Japan			No
11-15163	01/22/1999	Japan			No

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	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)				
English language translation of an Office Action from the Chinese Patent Office dated 2003.					

Examiner	Date Considered	
*Examiner:	Initial if reference through citation if communication to	e considered, whether or not citation is in conformance with MPEP 609; draw line f not in conformance and not considered. Include copy of this form with next o applicant.
Form PTO 14	149	Patent and Trademark Office - U.S. Department of Commerce